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Tantalum (oxy)nitrides: Preparation, characterisation and enhancement of photo-Fenton-like degradation of atrazine under visible light

Yingxun Du*, Lu Zhao, Yaling Su

Nanjing Institute of Geography and Limnology, State Key Laboratory of Lake Science and Environment, Chinese Academy of Sciences, Nanjing 210008, China

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ABSTRACT

Tantalum (oxy)nitrides were prepared by the nitridation of Ta_2O_5 and were added to a photo-Fentonlike system to enhance Fe^{3+} reduction and atrazine degradation under visible light. The samples were characterized by XRD, XPS, DRS and BET analyses. XPS analysis showed that the nitrogen content of the tantalum (oxy)nitride samples increased noticeably with the nitridation temperature and nitridation time but slightly with the flow rate of NH₃. XRD results showed Ta_2O_5 was first converted to TaON and then to Ta_3N_5 when the nitridation temperature increased. DRS analysis showed that the sample obtained at 800 °C displayed the strongest absorption of visible light. However, the ability of the tantalum (oxy)nitrides to reduce Fe^{3+} did not increase continuously with the nitrogen content. Sample 7 (700 °C, $Q_{NH_3} = 0.3 \text{ L/min}, 6 \text{ h})$ showed the highest level of photocatalytic activity for Fe^{3+} reduction. This is because the photocatalytic activity of TaON for Fe^{3+} reduction is higher than that of Ta_3N_5 . And a slight synergetic effect was observed between TaON and Ta_3N_5 . With the addition of sample 7, H_2O_2 decomposition and atrazine degradation were significantly accelerated in a photo-Fenton-like system under visible light. The regenerated tantalum (oxy)nitrides catalyst displayed considerably stable performance for atrazine degradation.

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1. Introduction

The photo-Fenton-like (Fe^{3+}/H_2O_2) and photo-Fenton (Fe^{2+}/H_2O_2) systems constitutes one kind of the most attractive advanced oxidation processes, as the materials required are relatively abundant, inexpensive, and environmentally benign. In photo-Fenton-like and photo-Fenton system, the degradation of the contaminant is based on the attack of the active hydroxyl radical (•OH), which is generated by the reaction of Fe^{2+} and H_2O_2 (Eqs. (1) and (2)). A variety of refractory organics such as chlorinated phenols, herbicides and dyes can be decomposed effectively by the photo-Fenton(-like) reactions [1–6].

In photo-Fenton(-like) reaction, the cycling of the catalyst (Fe^{2+}/Fe^{3+}) is key to the effective degradation of the contaminant. Eqs. (1) and (3) showed the cycling of iron ions driven by H₂O₂. Fe²⁺ is oxidized by H₂O₂ with a high rate constant. But the reduction of Fe³⁺ by H₂O₂ is slow and thus ineffective. In photo-Fenton(-like)processes, the efficient way to reduce Fe³⁺ is the irradiation of UV light (λ < 360 nm) (Eq. (4)) [7]. However, the industrial applicability of this process is limited since natural UV comprises only 3–5% of the solar light energy that reaches the earth.

$Fe^{2+} + H_2O_2 \rightarrow Fe^{3+} + \bullet OH + OH^-$	$k_1 = 51 \mathrm{M}^{-1} \mathrm{s}^{-1}[8]$	(1)
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•OH +
$$P \xrightarrow{\text{AUOH}}$$
 intermediates (2)

$$Fe^{3+} + H_2O_2 \rightarrow Fe^{2+} + HO_2^{\bullet} + H^+ \quad k_3 = 0.001 - 0.01 \text{ M}^{-1} \text{ s}^{-1}[9]$$

$$Fe(OH)^{2+} \xrightarrow{h\nu} Fe^{2+} + \bullet OH$$
(4)

Many semiconductor compounds, especially TiO_2 have been used as the photocatalysts in the reactions driven by solar energy such as water splitting and photocatalytic degradation [10–13]. The modified TiO_2 such as metal-doped or/and nonmetal-doped TiO_2 possessed the photocatalytic activity under visible light [12,14–18].

Tantalum (oxy)nitrides (Ta₃N₅ and TaON) have narrow band gaps of 2.08 and 2.4 eV [19], respectively, making them suitable as visible-light driven photocatalysts. With respect to the modified TiO₂ such as Ce–N codoped TiO₂, C–N codoped TiO₂ and bimetal codoped (Bi-Co and Fe-Co) TiO₂ [12,15,17], Ta₃N₅ and TaON have relatively simple composition and structure. It has been found that TaON and Ta₃N₅ were novel photocatalysts suitable for water decomposition and pollutant degradation reactions driven by visible light [20–22]. Compared with TiO_{2–x}N_x in the same size, Ta₃N₅

^{*} Corresponding author. Tel.: +86 025 86882116; fax: +86 025 57714759. *E-mail address:* yxdu@niglas.ac.cn (Y. Du).

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Composition, BET surface area and the ability to reduce	ice Fe ³⁺ of the tantalum ((oxy)nitride samples prei	pared under various conditions.

No.	Conditions	Ta:O:N	Specific surface area (m ² /g)	Fe ²⁺ (mg/L)	Reduction of Fe ³⁺ (%)
1	600 °C, 0.1 L/min, 6 h	1:3.0:0.10	0.896	0.129	0.45
2	600 °C, 0.5 L/min, 6 h	1:2.67:0.26	1.000	0.317	1.12
3	600 °C, 0.3 L/min, 6 h	1:2.62:0.34	1.548	0.534	1.90
4	700 °C, 0.1 L/min, 6 h	1:2.18:0.66	9.014	1.489	5.31
5	700 °C, 0.3 L/min, 2 h	1:3.32:0.24	1.894	0.425	1.51
6	700 °C, 0.3 L/min, 4 h	1:2.0:0.86	9.796	1.737	6.19
7	700 °C, 0.3 L/min, 6 h	1:1.86:0.80	14.25	2.003	7.15
8	800 °C, 0.3 L/min, 2 h	1:1.88:0.94	9.433	1.586	5.65
9	800 °C, 0.3 L/min, 6 h	1:1.50:1.07	8.549	1.171	4.17
10	800 °C, 0.1 L/min, 6 h	1:1.44:1.03	9.656	1.320	4.70
11	800 °C, 0.5 L/min, 6 h	1:1.16:1.17	9.654	0.700	2.50

showed much higher photocatalytic activity for the degradation of methylene blue under visible light irradiation [20]. To improve the efficiency of photo-Fenton system under visible light irradiation, Wang et al. [23] introduced Ta_3N_5 into the photo-Fenton system and found that Ta_3N_5 was effective to promote the reduction of Fe^{3+} under visible light and thus the degradation of N,N-dimethylaniline and 2,4-dichlorophenol. The mechanism of iron ions cycling in the presence of Ta_3N_5 was also proposed. Under visible light, Ta_3N_5 is excited to form electrons in the conduction band and holes in the valence band. The photoelectrons are captured by Fe^{3+} to generate Fe^{2+} , while the generated Fe^{2+} is oxidized by H_2O_2 immediately to regenerate Fe^{3+} and thus a rapid iron ions cycling is established.

Tantalum (oxy)nitrides are usually obtained by the nitridation of Ta_2O_5 in a NH₃ flow. The nitridation reaction always leads to the formation of a mixture of TaON and Ta_3N_5 [19]. The composition of the prepared sample was affected by the nitridation temperature, the nitridation time and the flow rate of NH₃. Thus, the preparation condition should influence the photocatalytic activity of the samples. However, to the best of our knowledge, little information on the photocatalytic activity for Fe³⁺ reduction of the samples prepared under various conditions is available.

In this study, the tantalum (oxy)nitride samples were prepared by the nitridation of Ta_2O_5 at first. XPS and DRS analysis showed that increasing the nitridation temperature, the nitridation time and the flow rate of NH₃ led to the higher content of nitrogen and the stronger absorption of visible light. But it was interesting to find that the photocatalytic activity for Fe³⁺ reduction is not increased continuously with the nitrogen content. This is because the photocatalytic activity of TaON for Fe³⁺ reduction is higher than that of Ta₃N₅, confirmed by the experimental data. And a slight synergetic effect was observed between TaON and Ta₃N₅. In the photo-Fenton-like system under visible light, the degradation of atrazine was significantly accelerated by the tantalum (oxy)nitrides sample. And the regenerated catalyst was considerably stable for atrazine degradation.

2. Experimental

2.1. Materials

 Ta_2O_5 , $Fe_2(SO_4)_3$ and hydrogen peroxide (30%) were purchased from Sinopharm Chemical Reagent Co., Ltd., China. NH₃ (99.99%) was supplied by Special Gas Co., Ltd., Nanjing, China. Atrazine was from Tokyo Chemical Industry Co., Ltd., Japan. Deionized water was used throughout this study.

2.2. Preparation and characterisation of tantalum (oxy)nitrides

For the preparation of tantalum (oxy)nitrides, 2.0 g of Ta_2O_5 was put into a quartz tube, which was put into a tube furnace and then subjected to nitridation under a flow of NH₃ at rates

ranging from 0.1 to 0.5 L/min. The nitridation temperature ranged from 600 to 800 $^{\circ}$ C, and the nitridation time was 2–6 h. After the reaction, the sample was cooled to room temperature in the flow of N₂. The detailed conditions for the preparation of each sample are summarized in Table 1.

The phase composition of the sample was characterized by Xray diffraction (XRD) (model D/max-rA, Rigaku Co., Tokyo, Japan), using Cu K α radiation. X-ray photoelectron spectroscopy (XPS) analysis was carried out on a RBD-upgraded PHI-5000C ESCA system (Perkin Elmer) with Mg K α radiation ($h\nu$ = 1253.6 eV). Binding energies were calibrated with containment carbon (C1s = 284.6 eV). The specific surface area of the powders was determined by nitrogen absorption (BET, ASAP 2020M Analyzer, Micromeritics). UV-vis diffuse reflectance spectra (DRS) were recorded on a UV-2401 Shimadzu spectrometer.

2.3. Photocatalytic reactions and analysis

Experiments were carried out in a photoreaction apparatus, which is shown in Fig. 1. The apparatus consists of two parts. The first part is an annular quartz tube and cooling water passes through an inner thimble of the annular tube. In the axial center of the reactor, there is a 500W xenon lamp as the light source. The wavelength of the visible light is controlled through a 400 nm cut filter. The second part is a 50 mL quartz tube, which is put on a magnetic stirrer. The reaction solution in the quartz tube was stirred during the experiments. The distance between the light source and the surface of the reaction solution is 4 cm.

In the experiment, the solution of atrazine was put into the quartz tube at first, of which pH was adjusted to 2.6 with H₂SO₄ solution ($V_{H_2SO_4}$: $V_{deionized water} = 1$: 20). Then Fe³⁺ stock solution (pH 2.6) and 0.03 g tantalum (oxy)nitrides were put into the tube. To achieve an adsorption/desorption equilibrium of Fe³⁺ and atrazine on the surface of the tantalum (oxy)nitrides, the suspension was kept in the dark and stirred for 30 min. After that, the stock solution of H₂O₂ was put into the tube and at the same time the lamp was turned on to initiate the photoreaction. The samples were taken out at the desired time intervals and filtered with a 0.22 µm Millipore filter to remove the catalyst. In the experiment of Fe³⁺ photoreduction, the procedure was similar except that no atrazine and H₂O₂ was added.

Analysis of atrazine was conducted on an Agilent 1120 compact HPLC system with a reversed phase C 18 column and UV detector. The UV detector wavelength was set at 235 nm. The mobile phase was 70:30 (v/v) of methanol and deionized water with a flow rate of 1.0 mL/min. The potential reaction of atrazine with hydroxyl radical was prevented by adding 1.0 mL of 1.0 M *tert*-butyl alcohol to the sample.

The concentration of Fe²⁺ was measured by the *o*-phenanthroline colorimetric method ($\lambda = 510$ nm, $\varepsilon = 1.1 \times 10^4 \text{ M}^{-1} \text{ cm}^{-1}$) [24]. The concentration of H₂O₂ was



Fig. 1. Schematic diagram of the experimental set-up: 1. Lamp, 2. Water-cooled jacket, 3. 400 nm cut filter, 4. Quartz tube, 5. Magneton, 6. Magnetic stirrer.

determined by a spectrophotometric analysis using the potassium titanium (IV) oxalate method [25].

3. Results and discussion

3.1. Characterisation of tantalum (oxy)nitride samples

3.1.1. XPS analysis of tantalum (oxy)nitrides

XPS analysis was used to determine the composition of the tantalum (oxy)nitride samples. Table 1 summarizes the ratios of Ta:O:N in the tantalum (oxy)nitride samples prepared under different conditions. The content of nitrogen in the tantalum (oxy)nitride samples increased with increasing nitridation temperature, nitridation time and flow rate of NH₃. Within the range adopted in this study, the effects of nitridation temperature and nitridation time on the nitrogen content of the samples are significant. At nitridation temperatures of 600, 700 and 800 °C (in a 0.3 L/min NH₃ flow for 6 h), the ratios of N to O were 9.7%, 43.0% and 71.3%, respectively. The ratios of N to O were 7.2%, 43.0% for the nitridation times of 2 and 4 h, respectively (at 700 °C in a 0.3 L/min NH₃ flow). While the effect of NH₃ flow rate was relatively slight. The ratios of N to O were 30.6% and 43.0% at NH₃ flow rates of 0.1 and 0.3 L/min, respectively (at 700 °C for 6 h).

Fig. 2(a) and (b) shows the O1s and N1s XPS spectra of Ta_2O_5 and the samples produced at the nitridation temperatures of 600, 700 and 800 °C, respectively. The peak positions of the O1s and N1s spectra were very similar in all samples. While the peak areas of O1s and N1s changed in opposite, as the areas assigned to O1s decreased with nitridation temperature, and the areas assigned to N1s increased. Fig. 2(c) was the typical simulation of N1s peaks (sample 9 as an example). As could be seen, the N1s peak consisted of the peak with the binding energy of 395.67 eV, which was generally considered to be the evidence for the presence of Ta–N bonds when N atoms replace O atoms in Ta_2O_5 crystal lattices [19]. The



Fig. 2. O1s (a) and N1s (b) XPS spectra of Ta_2O_5 and the tantalum (oxy)nitride samples prepared at 600, 700 and 800 °C for 6 h at a flow rate of 0.3 L/min for NH₃; N1s (c) simulation of sample 9 (preparation conditions: temperature = 800 °C, $Q_{NH_3} = 0.3 \text{ L/min}$, time = 6 h).

replacement of the N atom by an O atom results in the band gap narrowing and a red shift of absorption for the tantalum (oxy)nitride samples [26,27]. Higher nitrogen content leads to a narrower band gap and stronger optical absorption in visible light domain.

3.1.2. XRD and DRS analyses

The nitridation reaction of Ta_2O_5 always leads to the formation of the mixture of TaON and Ta_3N_5 . Fig. 3 depicts the XRD



Fig. 3. XRD patterns of Ta_2O_5 (a) and tantalum (oxy)nitride samples prepared at 600 °C (b), 700 °C (c) and 800 °C (d).

patterns of Ta₂O₅ and tantalum (oxy)nitride samples prepared at 600, 700 and 800 °C for 6 h at a NH₃ flow rate of 0.3 L/min. The XRD patterns showed that reaction temperature had a significant effect on the nitridation of Ta₂O₅. With a nitridation temperature as low as 600 $^{\circ}$ C, the colour of Ta₂O₅ changed to yellow, indicating that the nitridation reaction was starting. However, almost none of the crystalline phase of TaON and Ta₃N₅ was detected by XRD. The samples which were prepared at 700 °C and 800 °C both consisted of Ta₂O₅, TaON and Ta₃N₅. Compared to the sample prepared at 700 °C, stronger diffraction peaks corresponding to Ta₃N₅ and weaker peaks assigned to TaON appeared in the sample prepared at 800 °C. During the nitridation process, tantalum in the oxidation state V can form two ionic-covalent nitride types, Ta₃N₅ and TaON. TaON is regarded as the intermediate between the oxide precursor of Ta₂O₅ and the fully nitrided phase of Ta₃N₅ [28]. As the reaction of Ta₂O₅ with NH₃ to form TaON and Ta₃N₅ is endothermic [29], the content of nitrogen increased with the nitridation temperature.

The colours of samples prepared at 600, 700 and 800 °C are yellow, orange and red, respectively. Fig. 4 shows the UV-vis diffuse reflectance spectra of tantalum (oxy)nitride samples prepared at 600, 700 and 800 °C for 6 h in the NH₃ flow rate of 0.3 L/min. The UV-vis diffuse reflectance spectrum of Ta₂O₅ is also shown. Compared with the absorption spectrum of Ta₂O₅, the tantalum (oxy)nitride samples showed an obvious red shift with a stronger absorption in the wavelength range from 400 to 800 nm. When the nitridation temperature increased, a further red shift and a stronger absorption of the tantalum (oxy)nitride samples were observed. Samples obtained at 600, 700 and 800 °C showed absorption edges of approximately 520 nm, 620 nm and 640 nm, respectively, while the absorption edge of Ta₂O₅ was approximately 330 nm. According to the theoretical calculation, Ta₃N₅ and TaON show band gaps at 2.08 eV and 2.4 eV, respectively [19,30]. The strongest optical absorption of the sample prepared at 800 °C was mainly attributed to the highest content of Ta₃N₅.

3.1.3. BET analysis

BET surface areas of the samples are also given in Table 1. From Table 1, the surface areas of the samples obtained at 600 °C decreased compared to that of the precursor of Ta₂O₅ (2.965 m²/g). Since little tantalum (oxy)nitrides was formed at 600 °C, the decrease of the surface area might be due to the sintering of Ta₂O₅ particles at the high temperature. The specific surface area of the sample obtained at 700 °C was largest compared to those at 600 °C



Fig. 4. UV-vis diffuse reflectance absorption spectra of Ta_2O_5 and tantalum (oxy)nitride samples prepared at 600, 700 and 800 °C for 6 h at the NH₃ flow rate of 0.3 L/min.

and 800 °C (in a NH₃ flow rate of 0.3 L/min for 6 h). XRD results showed that the contents of TaON followed 700 °C > 800 °C > 600 °C and the contents of Ta₃N₅ were 800 °C > 700 °C > 600 °C. Combined the results of XRD with BET, it may be included that the surface areas were TaON > Ta₃N₅ > Ta₂O₅.

3.2. Photocatalytic activity of tantalum (oxy)nitrides

3.2.1. Photocatalytic activity of tantalum (oxy)nitrides for Fe^{3+} reduction

Prior to the investigation into the photocatalytic activity of tantalum (oxy)nitrides, the adsorption of Fe^{3+} , H_2O_2 and atrazine on the samples was investigated; little adsorption was observed.

Table 1 also lists the generation of Fe^{2+} in Fe^{3+} solution after 180 min of irradiation with visible light with the addition of tantalum (oxy)nitride. It is interesting to find that the ability of tantalum (oxy)nitrides to reduce Fe^{3+} was apparently not determined by the nitrogen content and the absorption under visible light domain. The highest concentration of Fe^{2+} was achieved in the presence of sample 7 (preparation conditions: temperature = 700 °C, $Q_{\rm NH_3} = 0.3 \, \text{L/min}$, time = 6 h). The amount of Fe^{2+} generated in the presence of sample 7 was approximately 1.7 times the amount generated with sample 9. However, sample 9 has a higher nitrogen content and stronger visible light absorption.

XRD results showed that more TaON was contained in sample 7 and when the nitridation temperature increased to 800 °C (sample 9), some TaON changed to Ta₃N₅. Here we tried to compare the photocatalytic activity of TaON and Ta₃N₅ for Fe³⁺ reduction under visible light irradiation as such information is limited.

Firstly, the following two nitridation processes were conducted to obtain the pure TaON and pure Ta_3N_5 . Based on the previous reports [19,31,32], Ta_2O_5 was nitrided at 750 °C in a 0.06 L/min NH₃ flow for 12 h and at 850 °C in a 0.9 L/min NH₃ flow for 12 h to form TaON (sample 12) and Ta_3N_5 (sample 13), respectively. The XRD patterns of sample 12 and sample 13 are shown in Fig. 5. As could be seen, sample 13 was almost the pure Ta_3N_5 and the majority of sample 12 was TaON.

The photoreduction of Fe^{3+} under visible light irradiation for 3 h by sample 12, sample 13 and a mixture of sample 12 and sample 13 (w:w = 1:1) were investigated.

The reduction of Fe^{3+} over sample 12 (2.34 mg/L of Fe^{3+} formed after 3 h visible light irradiation) was significantly faster than that over sample 13 (1.03 mg/L of Fe^{3+} formed after 3 h visible light irradiation). It is concluded that the ability of TaON to reduce Fe^{3+} is



Fig. 5. XRD patterns of sample 12 (a) (nitrided at 750 $^\circ$ C in a 0.06 L/min NH₃ flow for 12 h) and sample 13 (b) (at 850 $^\circ$ C in a 0.9 L/min NH₃ flow for 12 h).

higher than that of Ta₃N₅. In the presence of the mixture of sample 12 and sample 13, there was 1.91 mg/L of Fe²⁺ formed, a little higher than 1.69 mg/L (the average of 2.34 mg/L and 1.03 mg/L). This may be due to the synergism between TaON and Ta₃N₅ for the photoreduction of Fe³⁺.

TaON and Ta₃N₅ have been reported as the visible-light photocatalyst to decompose water to H₂ and O₂. It was also found that the reduction of H⁺ to H₂ over TaON was higher than over Ta₃N₅ [31]. The difference of the photocatalytic activity between TaON and Ta₃N₅ is similar to that of the two phases of TiO₂, anatase and rutile. Anatase has a band gap of 3.2 eV, while rutile has a smaller band gap of 3.0 eV. Nevertheless, anatase is generally regarded as the more photochemically active phase of TiO₂, presumably due to the combined effect of lower rates of recombination and higher surface adsorptive capacity [33]. In addition, the mixing of an active phase (anatase) with a comparatively inactive phase (rutile) produces a class of photocatalysts with higher activity [34,35].

The BET results showed that sample 12 has higher specific surface area (10.052 m³/g) than sample 13 (6.731 m³/g), which could be one of the reasons for the higher photocatalytic activity of TaON. Other factors to influence the photocatalytic activity of TaON and Ta₃N₅ need exhaustive investigation in the further work.

3.2.2. Enhancement of Fenton reaction and atrazine degradation by tantalum (oxy)nitrides

Fig. 6(a) shows the generation of Fe^{2+} by various systems under visible light. No H_2O_2 was added in these systems. Little ferrous ion was generated in Fe^{3+} solution either without catalyst or with Ta_2O_5 . With the addition of sample 7, Fe^{2+} was produced continuously under the irradiation of visible light and then slowed down. After 180 min of irradiation, more than 2 mg/L of Fe^{2+} had been produced.

In the presence of H_2O_2 , the generated Fe^{2+} could decompose H_2O_2 to •OH. Fig. 6(b) shows the decomposition of H_2O_2 in a photo-Fenton-like system, a photo-Fenton-like system with Ta_2O_5 (called photo-Fenton-like- Ta_2O_5 system) and a photo-Fenton-like system with tantalum (oxy)nitride (sample 7) (called photo-Fenton-like-tantalum (oxy)nitride system) under visible light. In the systems of photo-Fenton-like and photo-Fenton-like- Ta_2O_5 , the decomposition of H_2O_2 was very slow, only 20–30% of H_2O_2 was consumed after 180 min. The decomposition of H_2O_2 in these two systems was due to Eqs. (1) and (3). Fe³⁺ firstly reacted with H_2O_2 to generate Fe²⁺ at a very slow rate of 0.01–0.001 M⁻¹ s⁻¹, and then Fe²⁺



Fig. 6. Reduction of Fe³⁺ (a) and decomposition of H_2O_2 (b) in various systems under visible light: $[Fe^{3+}]_0 = 28 \text{ mg/L}$, $[H_2O_2]_0 = 2.5 \text{ mM}$, input of tantalum (oxy)nitride = 0.6 g/L, pH 2.6.



Fig. 7. Degradation of atrazine in various systems under visible light: $[Fe^{3+}]_0 = 28 \text{ mg/L}, [H_2O_2]_0 = 2.5 \text{ mM}, [atrazine]_0 = 18 \text{ mg/L}, input of tantalum (oxy)nitride = 0.6 g/L, pH 2.6.$



Fig. 8. (a) Degradation of atrazine over the fresh and regenerated tantalum (oxy)nitride samples in photo-Fenton-like system for four experimental runs (b) XRD patterns of a fresh and a regenerated samples: $[Fe^{3+}]_0 = 28 \text{ mg/L}$, $[atrazine]_0 = 18 \text{ mg/L}$, input of tantalum (oxy)nitride = 0.6 g/L, pH 2.6.

catalyzed H₂O₂ to •OH and was oxidized to Fe³⁺. A cycling of Fe²⁺/Fe³⁺ was established, with slow decomposition of H₂O₂. In the system of photo-Fenton-like-tantalum (oxy)nitrides (sample 7), more than 96% of H₂O₂ was decomposed after 180 min. This is due to the enhancement of Fe³⁺ reduction by the tantalum (oxy)nitrides.

The enhancement of the photo-Fenton-like degradation of contaminants by tantalum (oxy)nitrides under visible light was also investigated. Atrazine was chosen as a target pollutant because atrazine has no absorption under visible light. Because atrazine or the intermediates of atrazine cannot interact with Fe³⁺/Fe²⁺, which was different to aromatic compounds [36], the generation of Fe²⁺ during the degradation of atrazine could be regarded solely as the role of tantalum (oxy)nitrides.

Fig. 7 shows the changes in atrazine concentration in different systems under visible light. Atrazine scarcely underwent direct photolysis (data no shown). In systems where only Fe^{3+} or Ta_2O_5 was added, little degradation of atrazine was observed under visible light. In the presence of tantalum (oxy)nitrides and H_2O_2 , atrazine could hardly be degraded. In the process of dark-Fenton-like-tantalum (oxy)nitrides, approximately 19% of the atrazine was degraded after 3 h reaction. In the process of photo-Fenton-like, the trend of atrazine degradation is similar to that of dark-Fenton-like-tantalum (oxy)nitrides. In these two systems, Fe^{3+} was slowly reduced to Fe^{2+} through H_2O_2 (Eq. (3)). And then the Fenton reac-

tion (Eq. (1)) produced •OH, resulting in a slight degradation of atrazine. With the addition of tantalum (oxy)nitrides (sample 7), the degradation of atrazine in a photo-Fenton-like system was obviously enhanced. After 120 min of irradiation with visible light, atrazine was degraded completely.

3.2.3. Reusability of tantalum (oxy)nitrides photocatalyst

Fig. 8(a) shows the reusability of the tantalum (oxy)nitrides (sample 7) in photo-Fenton-like system during four experimental runs. As could be seen, the degradation of atrazine in the second run was slower than that in the first run. Compared with that over the fresh catalyst, the percentage of atrazine degradation decreased by about 25% at 60 min and 8% at 90 min in the second run. Nevertheless, almost all atrazine was also removed after 120 min in the second run. In addition, it was encouraging that the degradation rate of atrazine was almost the same in the second, third and fourth runs.

The XRD patterns of a fresh catalyst sample and a regenerated catalyst sample are compared in Fig. 8(b). The two XRD patterns was similar except that the peaks corresponding to TaON at 2θ of 29.0 and 32.6° were a little lower in the regenerated catalyst. When the fresh tantalum (oxy)nitrides catalyst was subjected to the photo-Fenton-like system in the first run, the component of the catalyst changed a little and the photocatalytic activity decreased. But after that, the tantalum (oxy)nitrides catalyst became stable and showed good activity for atrazine degradation.

4. Conclusion

Tantalum (oxy)nitrides were prepared by the nitridation of Ta₂O₅ at 600-800 °C in a NH₃ rate of 0.1-0.5 L/min for 2-6 h. XPS analysis showed that the degree of nitridation was significantly affected by the nitridation temperature and the nitridation time. The N1s XPS spectra confirmed the replacement of O atoms by N atoms to form Ta-N bonds in the Ta₂O₅ crystal lattice. With the increase of the nitridation temperature, Ta₂O₅ was converted into TaON and then to Ta₃N₅. DRS analysis showed that the tantalum (oxy)nitride samples prepared at 600, 700 and 800 °C possessed absorption edges around 520, 620 and 640 nm, respectively. But the ability of the tantalum (oxy)nitride samples to reduce Fe³⁺ did not increase continuously with the nitrogen content and the absorption range under visible light. The generation of Fe²⁺ in the presence of sample 7 (nitrided at 700 °C) was approximately 1.7 times that generated with sample 9 (nitrided at 800 °C). This was because the photoactivity for Fe³⁺ reduction of TaON is much higher than Ta₃N₅.

With the addition of sample 7, H_2O_2 was efficiently decomposed to generate hydroxyl radicals in a photo-Fenton-like system under visible light. The degradation of atrazine was significantly accelerated and almost all atrazine was degraded completely after 120 min. The regenerated tantalum (oxy)nitrides catalyst became stable after the first run and showed good activity for atrazine degradation.

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